

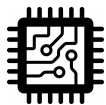


falkonry

Smarter Fab Operations

AI-driven Equipment Performance Visibility

Challenges in semi operations



Greater Precision for Higher Quality

Process variations can result in lower bin chips or even in scrap



Removing Unplanned Downtime

High utilization needed to meet market demand means increased opportunity costs of equipment failure



Resource Usage Optimization

Characterization and monitoring of equipment performance to minimize unnecessary power, water or chemical use



Maintain High Data/IP Security

Huge risks involved in the handling of confidential process and product data

AI for augmenting human ability is now necessary

Numerous low probability issues

to prevent and understand



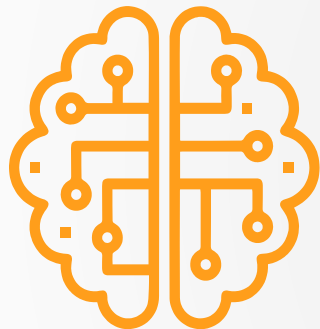
Faster data sampling

rates to achieve precision during
manufacturing



Large amount of time series data

is produced but is highly underutilized

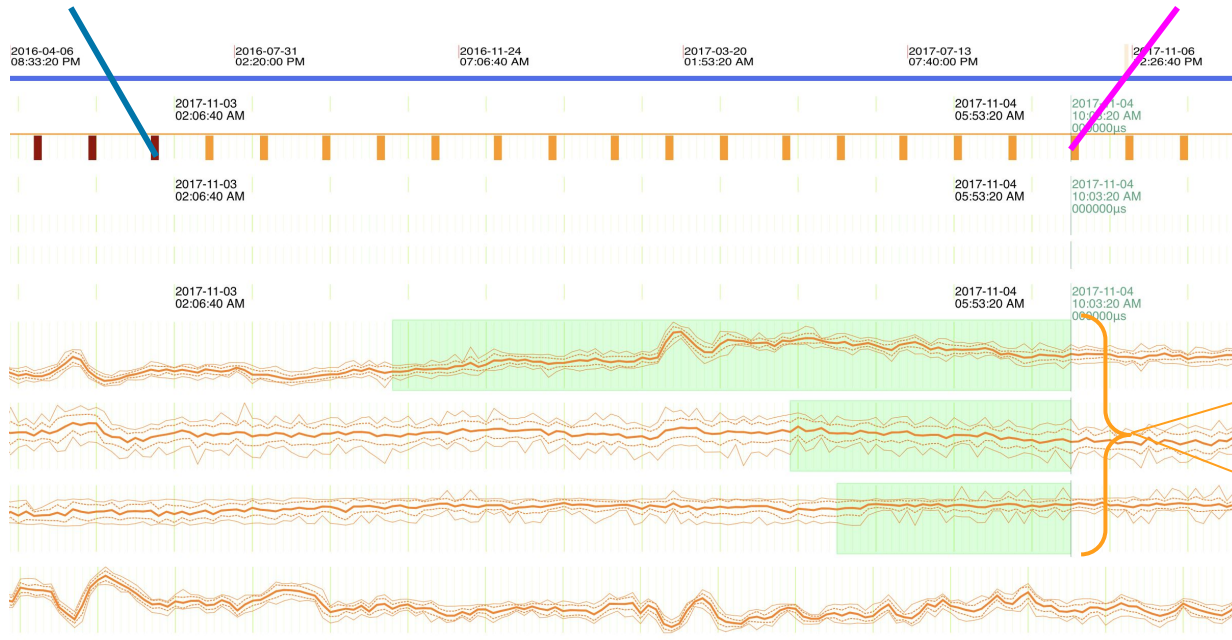


**Time series AI extracts facts of
equipment performance from
patterns in equipment data.**

Time series AI: Mining & organizing multivariate, temporal patterns

Condition 1

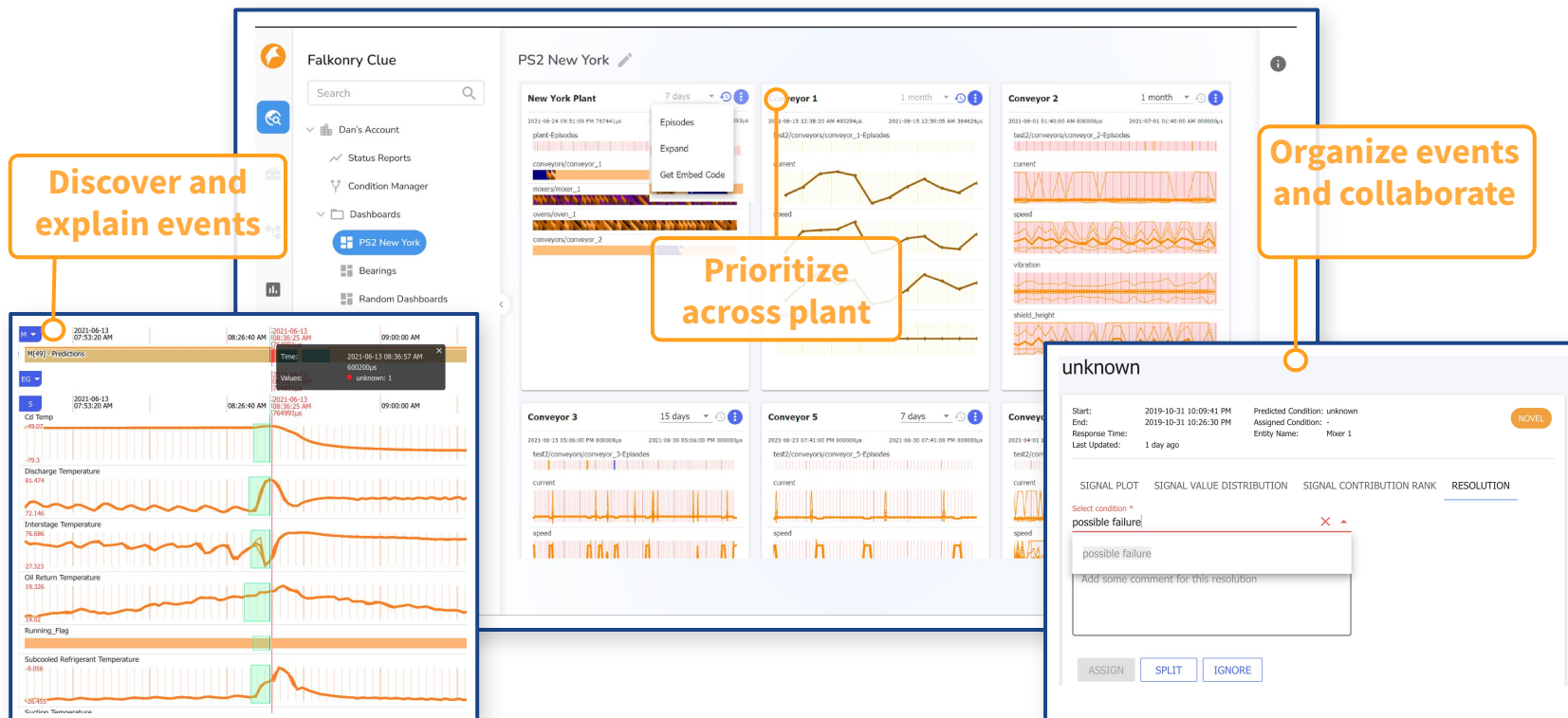
Condition 2



AI automatically discovers and distinguishes between conditions

Without requiring data scientists or data engineers

Falkonry enables smarter decisions with AI on time series data



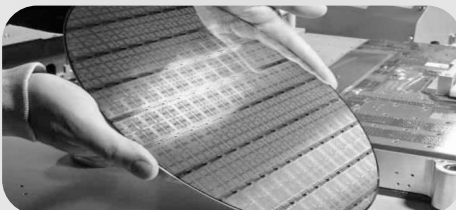
Smarter semi operations using time series AI

PREDICTIVE MAINTENANCE



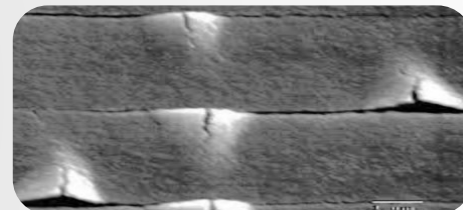
Etching

PREDICTIVE QUALITY



Metrology Sampling

ROOT CAUSE ANALYSIS



Delamination (Deposition)

EQUIPMENT FINGERPRINTING



Equipment installation
PM recovery

EQUIPMENT CHARACTERIZATION



New Equipment or process

Predictive maintenance of Ion Beam Etcher

PROBLEM

ESD damage to chamber and substrates occurring due to unexpected failure of neutralizer

SOLUTION

Time series AI on equipment sensor data detects variations in neutralizer behavior which indicate impending part failure

ADVANTAGES

Identify early part failure to reduce scrap and unscheduled equipment downtime

Neutralizer failure prediction development

1. Collect sensor data and known events
2. Review historical system behavior
3. Separate pre-failure from normal behavior
4. Verify on a different known event
5. Deploy against streaming data

Neutralizer failure prediction development: Step 1

1. Collect sensor data and known events
 - a. Etcher sensor data
 - b. Neutralizer failure events date+time
2. Review historical system behavior
3. Separate pre-failure from normal behavior
4. Verify on a different known event
5. Deploy against streaming data

~5 months of time series data from etcher sensors including:

- Currents & voltages
- Gas flow rates
- RF reflected power

Two confirmed neutralizer failure events

- Timestamp of each event

Neutralizer failure prediction development: Step 2

1. Collect sensor data and known events
2. Review historical system behavior
 - a. Unsupervised learning on sensor data
 - b. Compare failure events to unusual behavior
3. Separate pre-failure from normal behavior
4. Verify on a different known event
5. Deploy against new training data

Two confirmed neutralizer failure events

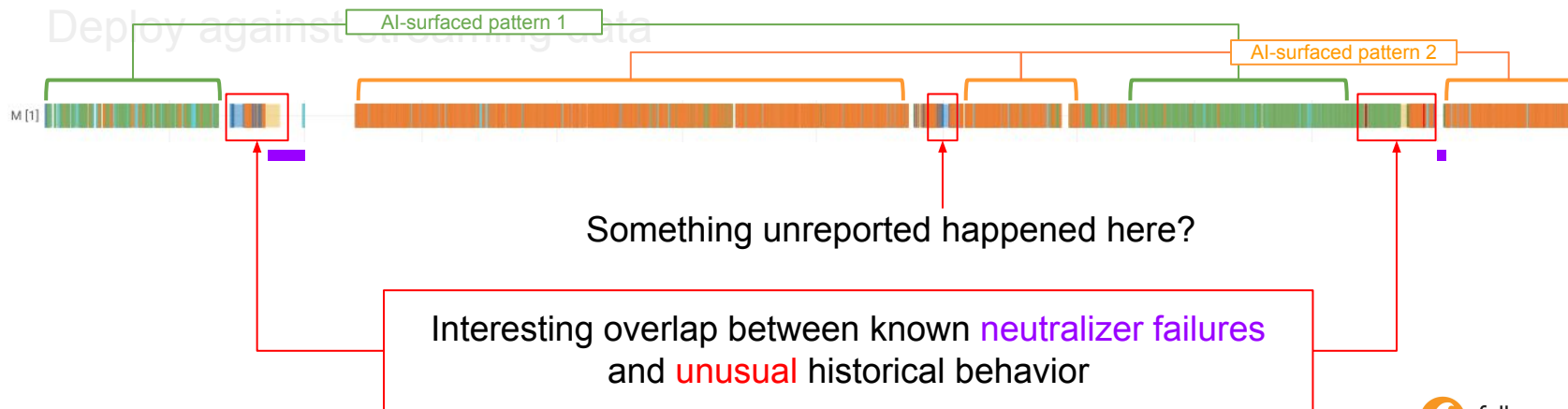
- Purple bars

Two main patterns of historical behavior

- Green and orange

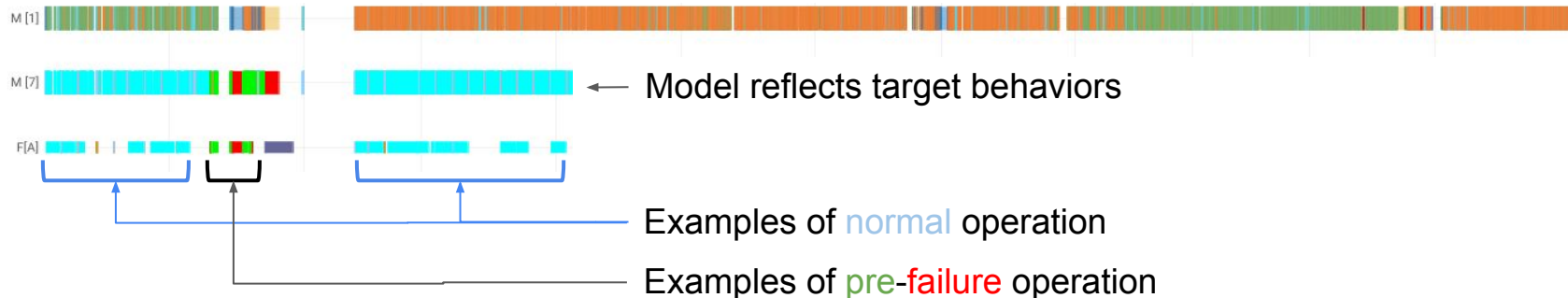
Three periods of “unusual” behavior

- Red boxes



Neutralizer failure prediction development: Step 3

1. Collect sensor and ground truth data
2. Understand historical system behavior
3. **Separate pre-failure from normal behavior**
4. Verify on a different known event
5. Deploy against streaming data



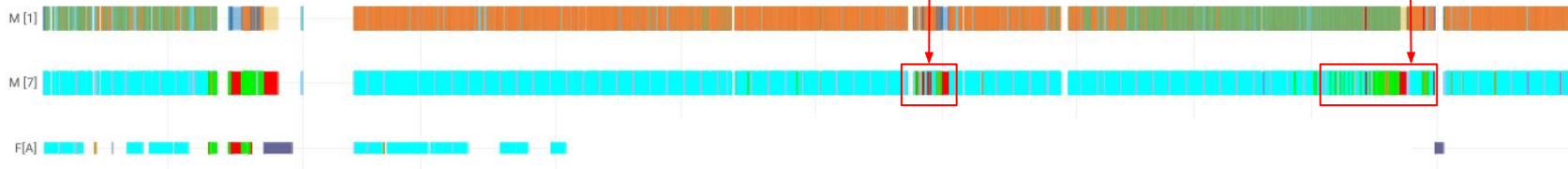
Neutralizer failure prediction development: Step 4

1. Collect sensor data and known events
2. Review historical system behavior
3. Separate pre-failure from normal behavior
4. Verify on a different known event
5. Deploy against streaming data

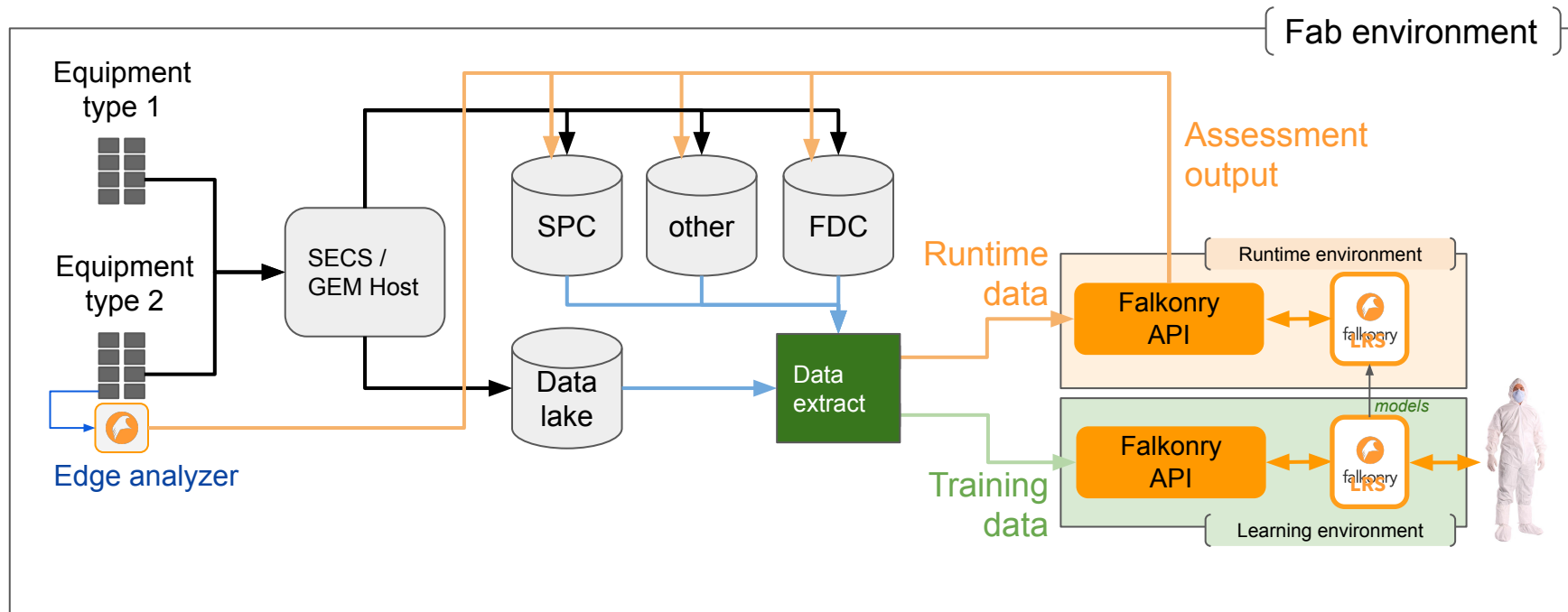
Abnormal patterns precede additional known neutralizer failure



Model indicates abnormal behavior. Was equipment serviced without a record?



Deploy against streaming data: Step 5



Architecture reads from and writes to existing data systems in the fab

Defectivity analysis of etching process

PROBLEM

Defect inspection adds time and cost to wafer processing

SOLUTION

Time series AI applied to etcher signal data finds patterns that differentiate low and high defectivity wafers

ADVANTAGES

Focus inspection on high-defectivity wafers to reduce inspection cost

Equipment fingerprinting and characterization

PROBLEM

PM performance errors result in lost productivity and reduced yield

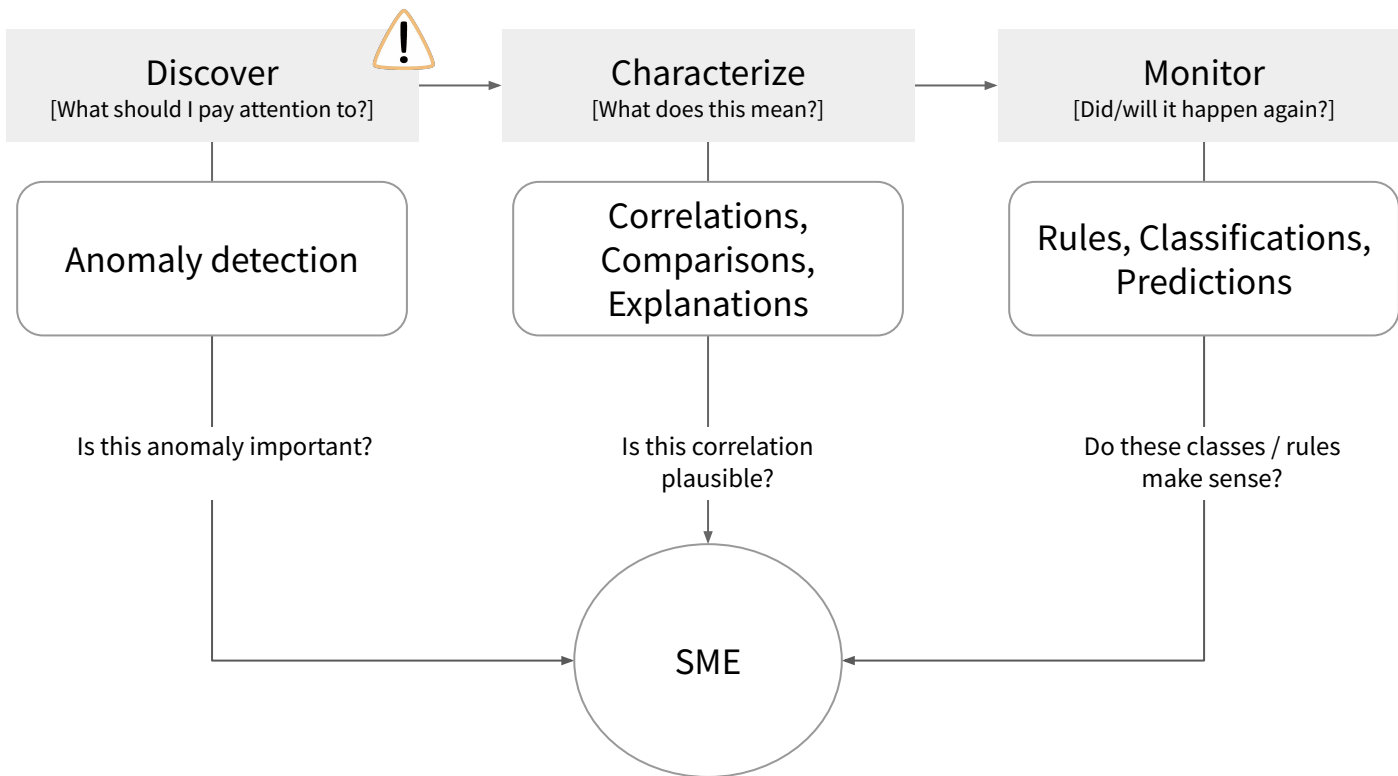
SOLUTION

Operational pattern of a reference process for a known good tool (“golden fingerprint”) is compared to the patterns of newly serviced / installed tools to report significant deviations.

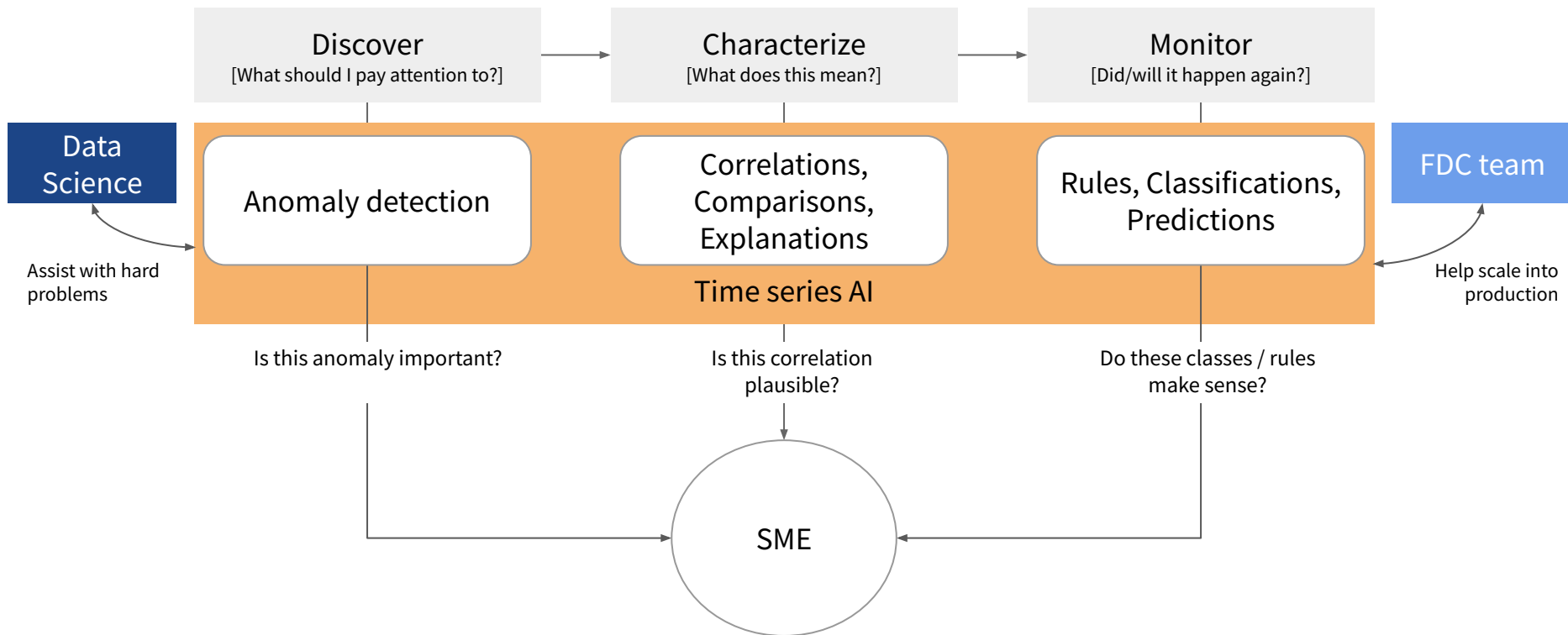
ADVANTAGES

Automate verification of PM and reduce downstream yield loss

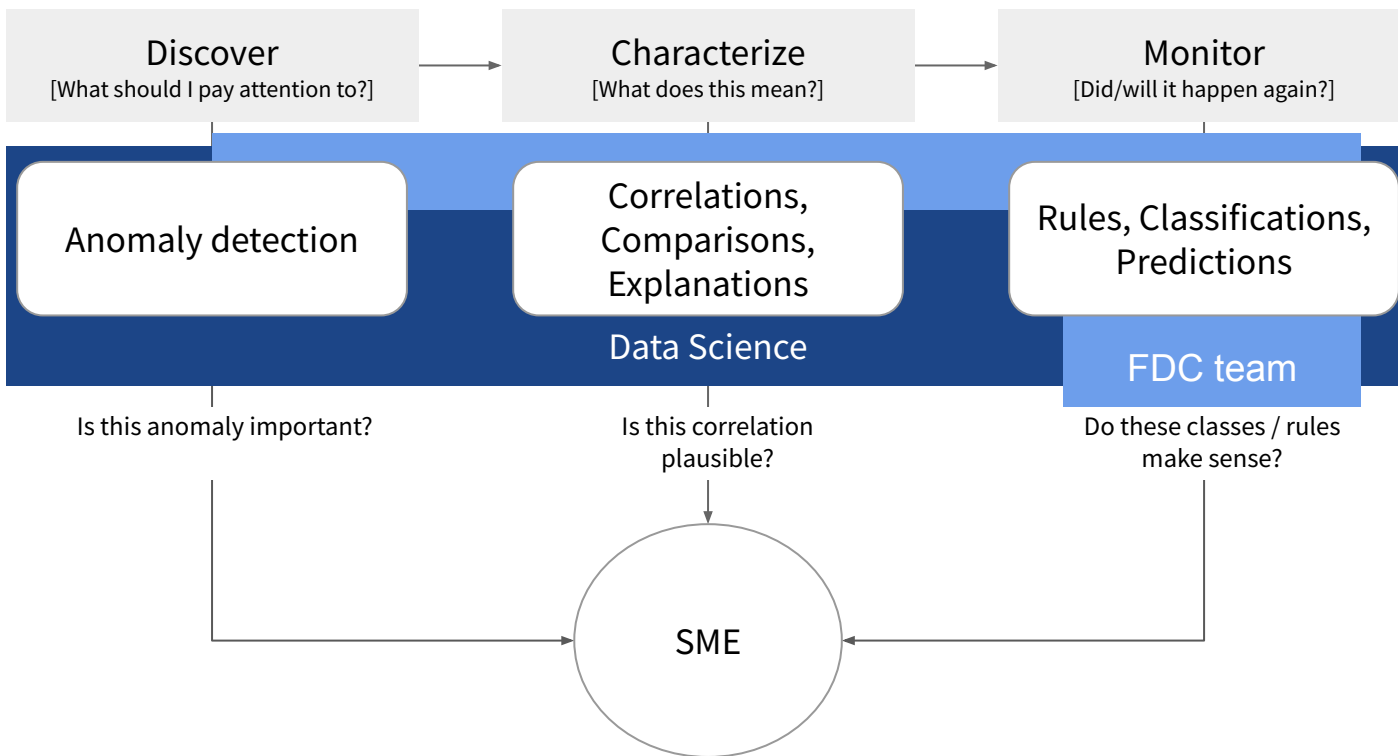
Subject matter experts are key to making sense of data



Time series AI allows subject matter experts to do tasks themselves



Coordination and alignment makes conventional data science hard



Key requirements for Time series AI

Fit into existing workflows



Daily Meetings

Analytic and reporting approach which supports daily operations



End-to-end workflows

Data sources and findings integrate across fab systems

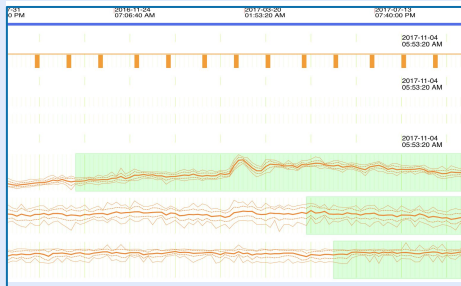
Usable by domain experts, not just data experts



Domain knowledge is as important as the right data for AI to be effective.

Achieving scale requires domain experts to be involved first-hand.

Understand the role of time



“Interesting” behaviors are time-dependent. Effectively handling different time scales is critical.

Explain insights and build expert confidence



Explanation



Actionable assessment

Falconry makes the *physical* world's information accessible and useful



HIGHLIGHTS IMPORTANT EVENTS

We focus human attention on important signals in very noisy data



WORKS FOR END-USERS

We do not need data scientists or data engineers



SAAS ANYWHERE

We run efficiently on any available compute

RECOGNIZED & RESPECTED



Highest private AI company recognition



A F W E R X

First large-scale strategic sensor DoD AI capability



Selected from 5,000 companies globally



21 Patents issued and pending globally



falkonry

Operational Excellence with AI



Dr. Nikunj Mehta

Founder & CEO
Falconry

Thank you!

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